

DETERMINATION OF ADHESION AND MECHANICAL PROPERTIES OF OPTICAL COATINGS BY NANOSCRATCH AND NANOINDENTATION

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Mechanical properties of optical film: external contact



Optical coatings are not primarily wear and scratch resistant

- Typical optical coatings (Mo, Si, TiO_2 , SiO_x , MgF_2) have rather low hardness and wear resistance

But optical components are in contact with hard materials

- Mechanical damage will deteriorate the optical properties³
- The coating can delaminate

The hard layer or the protection must have⁴

- High hardness
- High scratch resistance
- Do not interfere with optical properties



³Price, James et al. "Nanoindentation Hardness and Practical Scratch Resistance in Mechanically Tunable Anti-Reflection Coatings." *Coatings* 11 (February 2021).

⁴Paulson, Charles A. et al. "Industrial-Grade Anti-Reflection Coatings with Extreme Scratch Resistance." *Optics Letters* 44, no. 24 (December 15, 2019): 5977–80.

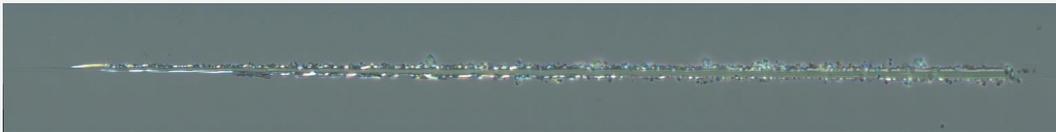
Challenge: optical coatings are thin

Typical thickness of optical coatings – related to wavelength

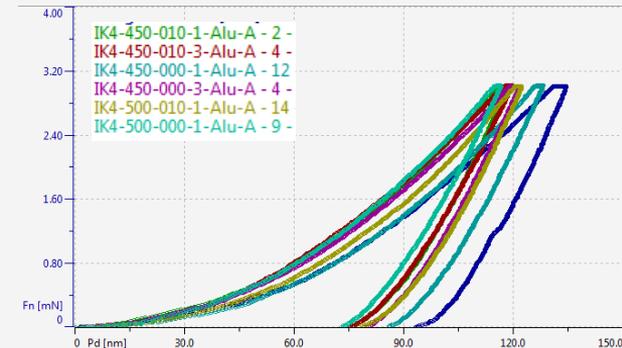
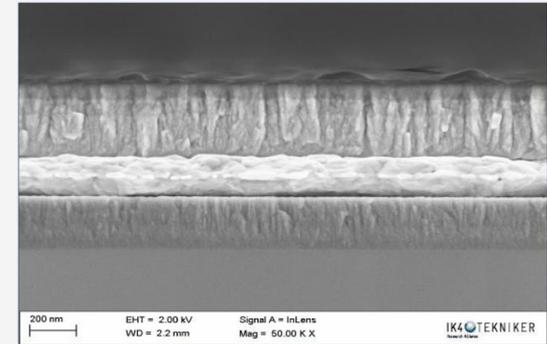
- Tens and hundreds of nanometers
- Often multilayers

How can we measure their hardness and scratch resistance – or even adhesion?

- Nanoindentation: using low forces and depth profiling
- Nanoscratch: scratch at low forces with optical or SEM analysis

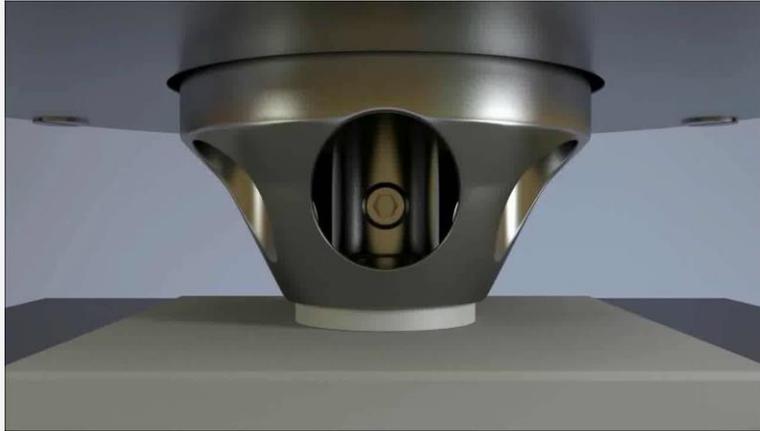


Multilayer absorber coating (Tekniker)



Nanoindentation

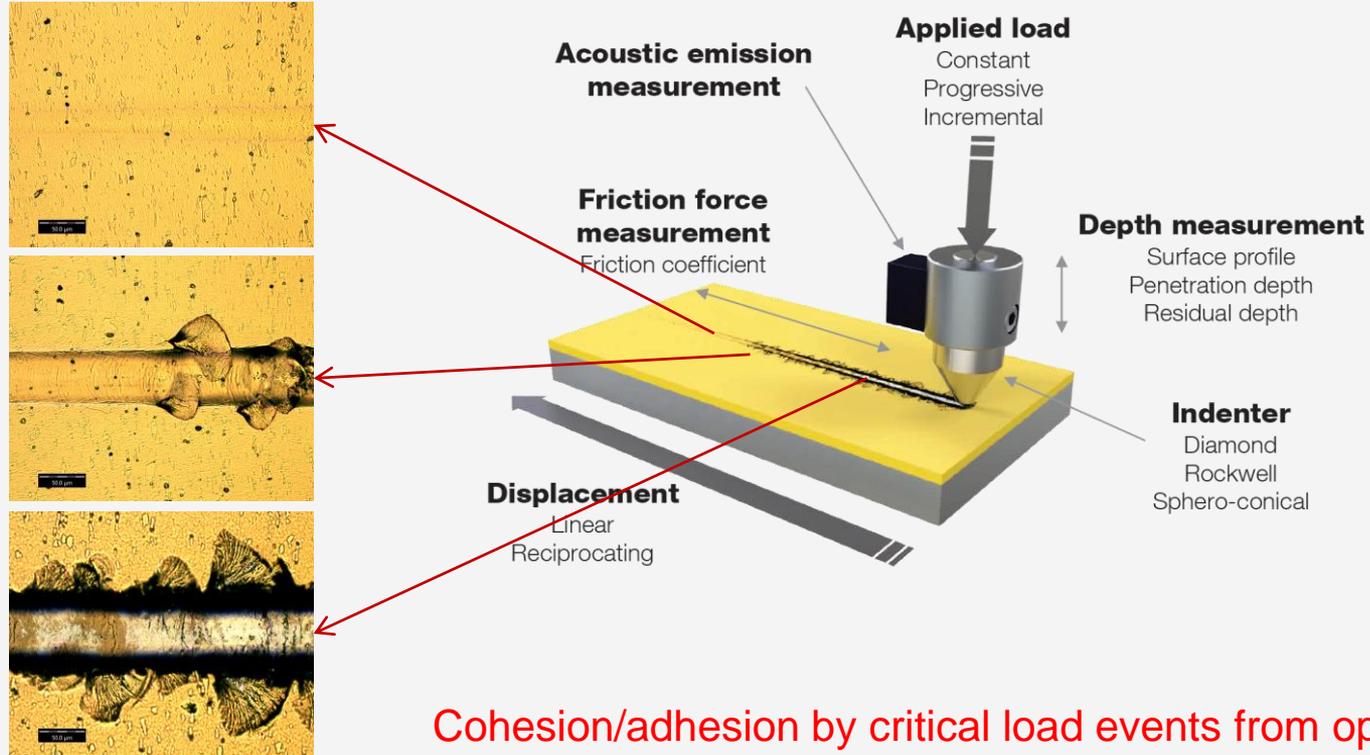
Hardness and elastic modulus of thin films



- We applied **force** and we measure **indentation depth**
- **Hardness** and **Elastic Modulus** are calculated from the **force-displacement curve**
- Anton Paar: surface referencing for increased thermal stability and elimination of frame compliance
- Lowest indentation depths down to ~5 nm
- Standardized hardness and elastic modulus calculations (ISO 14577)

Nanoscratch testing

For determination of scratch resistance and adhesion



Case study: AR coating on glass cover for photovoltaics

- Glass increases stiffness of the PV cells
- Protects the cells against mechanical damage
- Wear and damage from impacts of dust, rain and sand
- Scratching by hard particles but relatively low force
 - Glass is coated with antireflective coating
 - Large panels: sol-gel deposition method
 - Thickness of the coating: ~120 nm

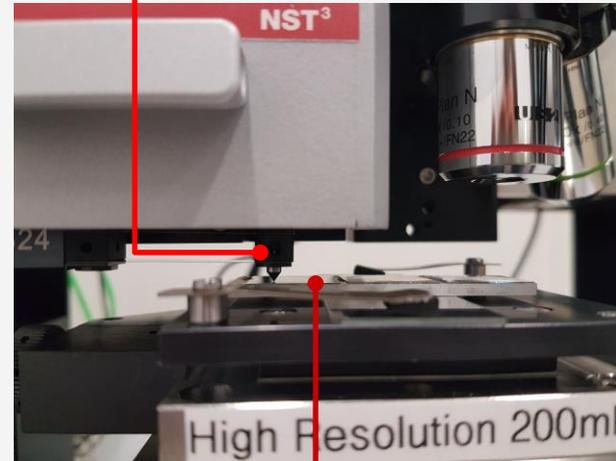


Characterization – nanoscratch & nanoindentation

Scratch tests by Nanoscratch Tester (NST)

- Low load – thin films
- 2 μm radius spherical diamond indenter

Spherical diamond indenter



Glass with AR coating

Berkovich diamond indenter



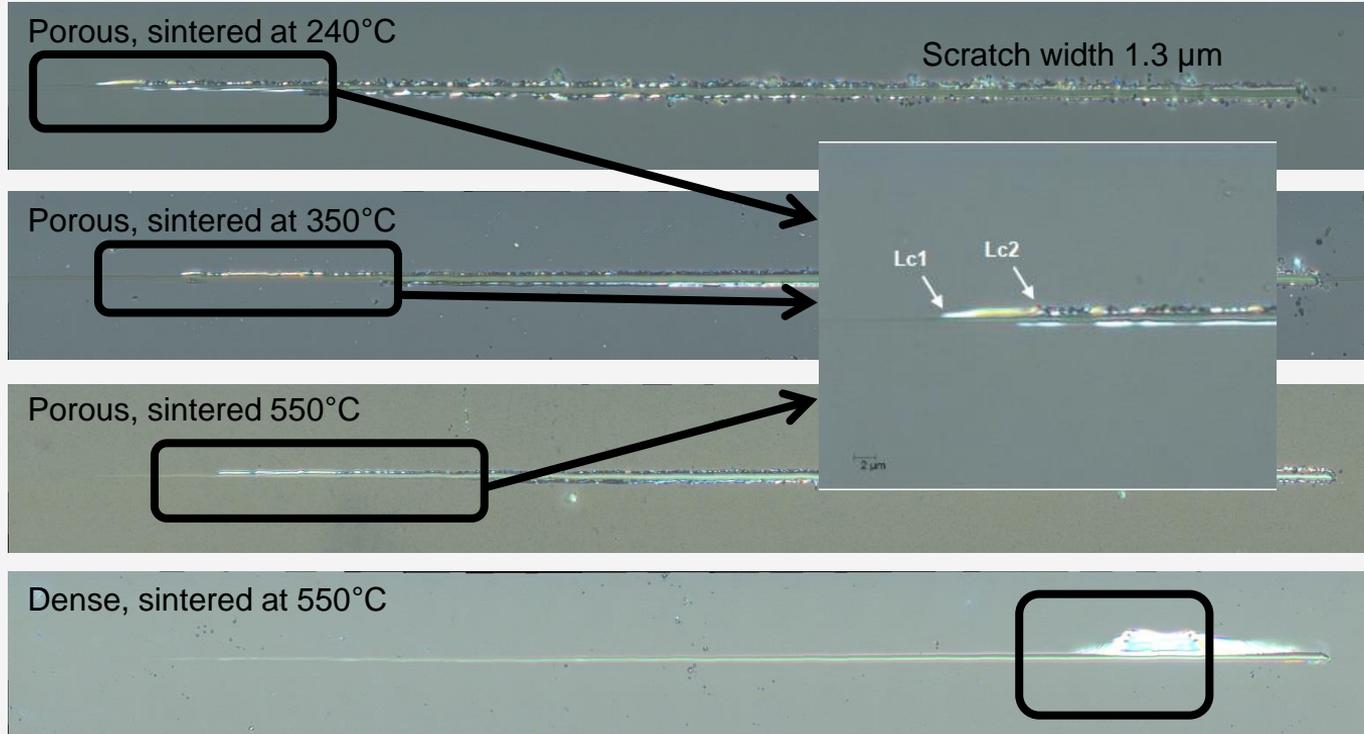
Active surface reference

Hardness and elastic modulus by UNHT

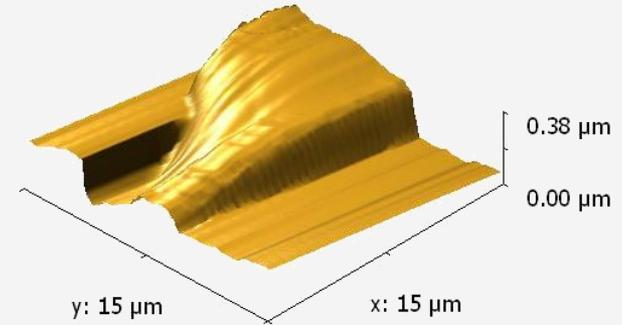
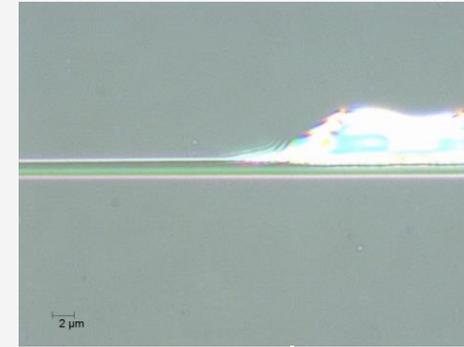
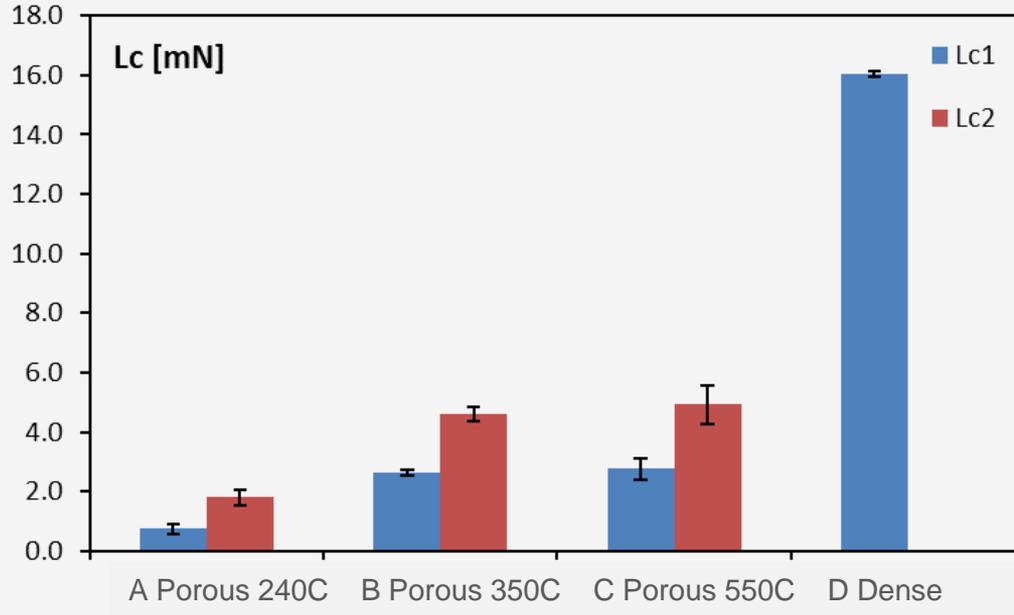
- Berkovich indenter (diamond)
- Force 10 μN up to 50 μN

Results – scratch test

Panorama image of the scratch track



Scratch: comparison of critical loads



Atomic force microscope (AFM)

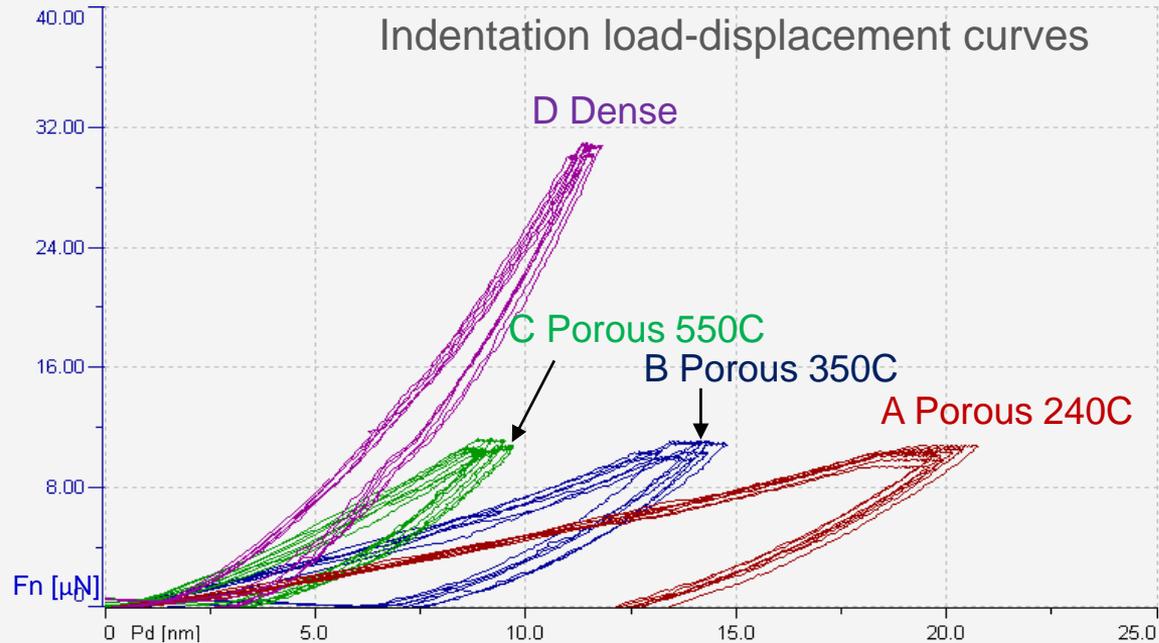
Conclusion – adhesion

- Nanoscratch can determine quickly the adhesion of thin AR films

Nanoindentation

Thin films (~ 100 nm) \Rightarrow low indentation depths & loads

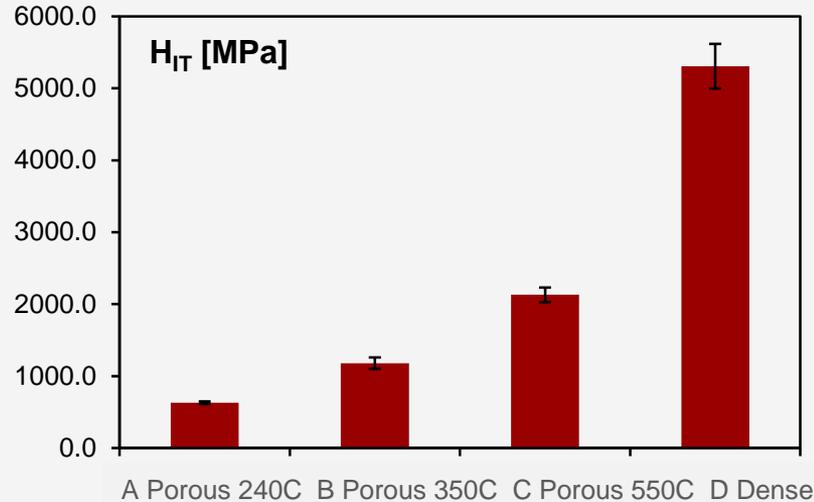
- F_{\max} 20 μN ,
- Maximum depth 10 nm to 20 nm



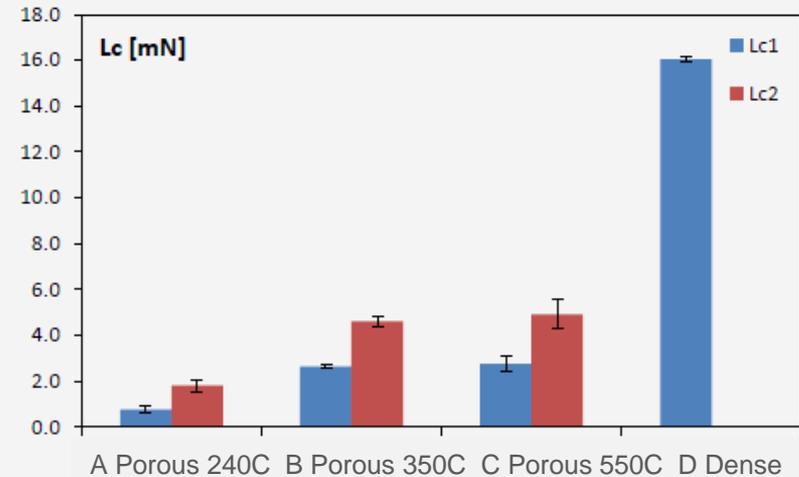
Indentation & scratch test results: comparison



Indentation



Scratch

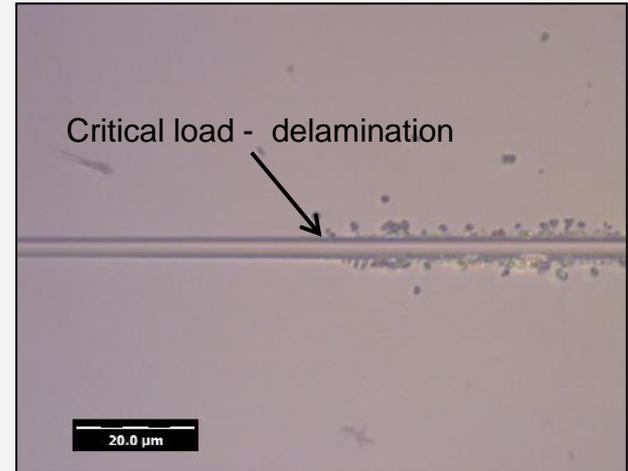
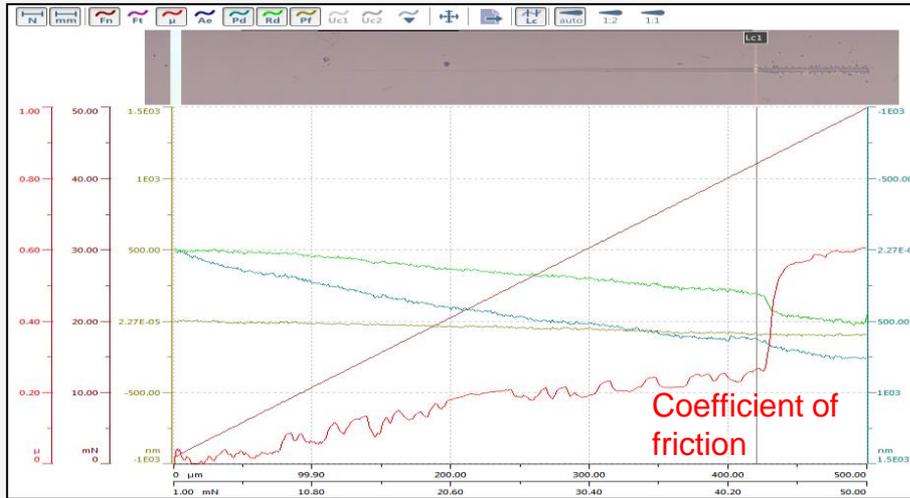


Correlation – harder films have better adhesion

- Not a rule - but this is why we measure it

Sapphire coated Gorilla glass: nanoscratch

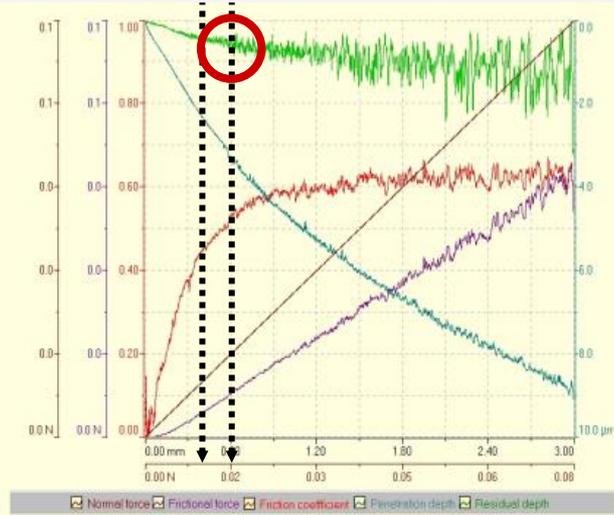
- Thin wear resistant film ~120 nm
- Critical load determined by integrated optical microscope
- Analysis of other signals (coefficient of friction) 'support' the optical analysis



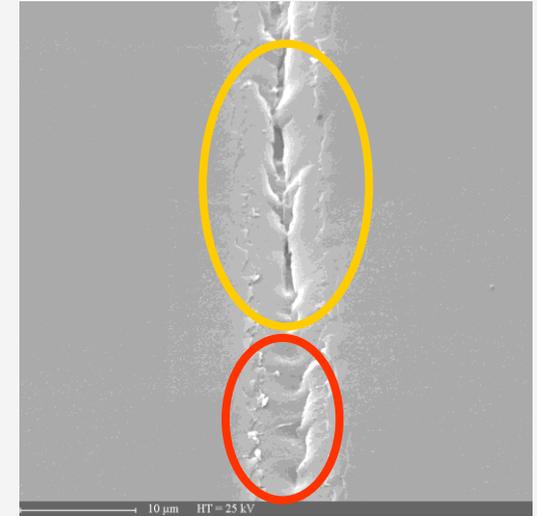
Typical data acquired during a progressive scratch with panorama image

Red curve: Coefficient of friction (CoF)

Nanoscratch is just the beginning



Integrated optical microscope



Scanning Electron Microscope (SEM)

SEM Observations – more detailed info about the film failure

- Critical load L_{c1} : Transition from AR layer → hard layer
- Critical load L_{c2} : Transition from hard layer → substrate

Nanoscratch & nanoindentation for optical layers



Nanoscratch: scratch resistance and adhesion by defined scratching

- Applicable also on very thin coatings (~50 nm)
- SEM for more details



Nanoindentation: hardness and elastic modulus of thin layers

- Indentation depths down to ~10 nm
- Automatic measurements

